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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/809,535	03/24/2004	Francis J. Kelley	02009US . 6145	
61611 75	590 11/24/2006		EXAMINER	
ROHM AND HAAS ELECTRONIC MATERIALS			CHEN, KIN CHAN	
CMP HOLDIN	· ·		ART UNIT	PAPER NUMBER
	451 BELLEVUE ROAD NEWARK, DE 19713			THE EN HOWELK
1,2,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,			1765 DATE MAILED: 11/24/2000	6

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
Office Action Summary		10/809,535	KELLEY ET AL.				
		Examiner	Art Unit				
		Kin-Chan Chen	1765				
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the c	correspondence address				
WHIC - Exter after - If NC - Failu Any	ORTENED STATUTORY PERIOD FOR REPLY CHEVER IS LONGER, FROM THE MAILING DANSIONS OF THE MAILING THE MAIL	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tin will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).				
Status							
1) 又	Responsive to communication(s) filed on <u>17 October 2006</u> .						
2a)⊠	This action is FINAL . 2b) This action is non-final.						
3)□	(
,	closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims		•				
4)⊠	4) Claim(s) <u>1-10</u> is/are pending in the application.						
	4a) Of the above claim(s) <u>6-10</u> is/are withdrawn from consideration.						
5)□							
6)⊠	_						
7) 🗌	,						
8)□	8) Claim(s) are subject to restriction and/or election requirement.						
Applicat	ion Papers						
9)[]	The specification is objected to by the Examine	er.					
10) ☐ The drawing(s) filed on is/are: a) ☐ accepted or b) ☐ objected to by the Examiner.							
,—	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).							
11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (under 35 U.S.C. § 119						
	Acknowledgment is made of a claim for foreign ☐ All b)☐ Some * c)☐ None of:)-(d) or (f).				
	1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No							
	3. Copies of the certified copies of the prior	•	ed in this National Stage				
	application from the International Bureau						
* See the attached detailed Office action for a list of the certified copies not received.							
			·				
Attachme-							
Attachmen	n(s) ce of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
	2) Notice of Draftsperson's Patent Drawing Review (PTO-948) Paper No(s)/Mail Date						
	3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 5) Notice of Informal Patent Application 6) Other:						
Pape	n Nu(s)/Mail Date	6)					

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DETAILED ACTION

Claim Rejections - 35 USC § 112

1. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

Claim 5 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 5 recites the composition comprising 0.01 to 10 weight percent abrasive. However, the base claim recites that the composition is abrasive free. They are conflicting.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1-4 are rejected under 35 U.S.C. 103(a) as being unpatentable over small (US 5,981,454) in view of Chopra (US 6,276,996) or Verhaverbeke (US 5,972,123) as

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evidenced by Grant & Hackh's Chemical Dictionary (page 121) and Hawley's Condensed Chemical Dictionary (page 1066).

Small teaches an aqueous composition useful for polishing copper on a semiconductor wafer. The composition may comprise oxidizer (col. 7, lines 54-55; col. 6, lines 18-29). The amount of oxidizer may vary from 0.5 to 30 wt. %, which overlaps the claimed range (col. 8, line 29). The complexing agent may be included (col. 6, lines 57-65). The concentration of complexing agent may vary from 1 to 25 wt. % (col. 7, line 22), which overlaps the claimed range and water. The pH of the composition may be between 3.5 and 7 (abstract), which overlaps the claimed range. The composition may be free of abrasive and free of polyacrylic acids.

Claim 1 differs from Small by specifying using inhibitor in the composition.

However, it is common in the art of cleaning and wet etching to use inhibitor when using oxidizing agent to contact the metal. Chopra (col. 2, lines 49-50) or Verhaverbeke (col. 5, line 32) is only relied on to show the well-known feature of using the inhibitor in the etching and cleaning composition. Hence, it would have been obvious to one with ordinary skill in the art to use inhibitor in the etching and cleaning composition because it is common in the art and because it is disclosed by Chopra (col. 2, lines 49-50) or Verhaverbeke in order to prevent corrosion of the metal. The concentration of the inhibitor of Chopra encompasses the claimed range.

A prior art which teaches a range within, overlapping, or encompassing) the claimed range anticipates the range or is sufficient to establish a prima facie case of obviousness. Titanium Metals v. Banner, 778 F.2d775, 227 USPQ 773, Fed. Cir.1985.Atlas Power v. Ireco, 51 USPQ2d 1943, Fed. Cir. 1999. Ex parte Lee, 31 USPQ2d 1105, BPAI 1993. In re Peterson, 315 F.3d 1325, 1330, 65 USPQ2d 1379, 1382-83 (Fed.Cir. 2003).

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Small teaches that the surfactants may be included in the composition (col. 8, lines 43-45). Small is not particular about the surfactant. Hence, it would have been obvious to one with ordinary skill in the art to use commonly used surfactant such as carboxy methyl cellulose (CMC), see Grant & Hackh's Chemical Dictionary (page 121) and Hawley's Condensed Chemical Dictionary (page 1066).

Claim 1 differs from the prior art by specifying various amount of additive (such as surfactant). However, It would have been obvious to one with ordinary skilled in the art to employ these components in combination for their known functions and optimize the amount of each additive. MPEP 2144.06.

The limitations of claims 1-3 have been addressed above and rejected for the same reasons, supra.

Dependant claim 4 differs from the prior art by specifying various degree of substitution and molecular weight of carboxy methyl cellulose. Because same are merely a matter of choices of design depending on the product requirements, in absence of any unexpected result which is different in kind and not merely in degree from the result of the prior art, it would be obvious to one skilled in the art to use various a degree of substitution and molecular weight of carboxy methyl cellulose in order to accommodate the specific product and meet the product requirement.

Response to Arguments

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4. Applicant's arguments have been considered but are moot in view of the new ground(s) of rejection.

Conclusion

- 5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Grant & Hackh's Chemical Dictionary (page 121) and Hawley's Condensed Chemical Dictionary (page 1066) show that carboxy methyl cellulose (CMC) is a surfactant (also called surface-active agent, emulsifier, or wetting agent).
- 6. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

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7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kin-Chan Chen whose telephone number is (571) 272-1461. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

November 16,2006

Kin-Chan Chen Primary Examiner Art Unit 1765